

HEIDELBERG INSTRUMENTS WEBINAR

Maskless Aligner - Fast prototyping without photo masks

Thursday June 24th, 4 - 4:45pm AEST

Webinar description: The Maskless Aligner series was first introduced in 2015. Since then, the maskless technology has become firmly established in research labs worldwide as well as in many small to mid-volume micro fabrication facilities. Application areas include MEMS, microfluidics, micro-optics, sensors, electronic components and many more. This webinar will give you an insight into our maskless lithography technology with emphasis on our maskless aligner series.

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Upcoming webinars with Nano Vacuum - Heidelberg Instruments:

1. DWL - Research & Industrial Grayscale Lithography Tool
2. ULTRA Laser Writer - Volume Pattern Generators
3. NanoFrazor - A Nanolithography Tool for 2D & 3D devices
4. LithoProf3D-GSII - 3D Lithography via Two-Photon Polymerization